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Enhanced photoelectrochemical nitrogen reduction to ammonia by a plasmon-active Au grating decorated with the $\text{gC}_3\text{N}_4@\text{MoS}_2$ heterosystem and plasmon-active nanoparticles†

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The electrochemical production of ammonia from nitrogen (so-called nitrogen reduction reaction – NRR) is one of the key tasks of modern electrochemistry. The use of photo-electrochemical approaches in the NRR allows the involvement of renewable sunlight energy and partially reduces the energy demand of the NRR process and increases its efficiency. For efficient photoelectrochemical NRR realization, a rational design of the photoelectrode used is required. In this work, we propose the design, creation, and optimization of a hybrid electrode, based on utilization of coupled 2D semiconductors and plasmonic hot spots. In our approach, the $\text{gC}_3\text{N}_4@\text{MoS}_2$ semiconductor (in the form of 2D flakes), with high catalytic activity towards the NRR is used as a redox-active material. For the involvement of sunlight energy, plasmon triggering is used in two modes: simple plasmonic triggering using a periodic Au grating and coupled plasmon triggering through the sandwiching of 2D $\text{gC}_3\text{N}_4@\text{MoS}_2$ flakes between the Au grating and different plasmon active nanoparticles (gold and silver nanoparticles with different shapes). We also carried out a series of calculations (including finite difference time domain estimation of plasmon energy distribution and density functional calculation) aimed at the estimation of the local value of plasmon energy and the NRR process under conditions of plasmon triggering. As a result of careful design and photoelectrode optimization, we were able to achieve $882.1 \mu\text{g h}^{-1} \text{mg}_{\text{cat}}^{-1}$ ammonia yield and 22.1% faradaic efficiency. The proposed photoelectrode design makes it possible to effectively use both the catalytic properties of the coupled semiconductors and the strengths of plasmon-assisted triggering.

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Introduction

Ammonia (NH_3) is an essential component in the production of numerous ammonium fertilizers. Recently, it was also proposed as an eco-friendly hydrogen carrier in the form of chemical bonds.^{1–6} Today, the fundamental reaction for ammonia production is the Haber–Bosch process, which however is unfavoured by high energy demands, hard synthesis conditions and utilization of fossil hydrogen.^{7–10} Such synthesis conditions

can be related to the high nitrogen binding energy (941 kJ mol^{-1}), non-polarity of the molecule and low polarization ability.^{7,11,12} In order to substitute the Haber–Bosch process and find a more acceptable alternative for ammonia production¹³ the electrochemical nitrogen reduction to ammonia is actually studied. The nitrogen reduction reaction (NRR) can be performed at atmospheric pressure with utilization of potentially renewable energy sources. Moreover, the NRR utilizes water as a source of hydrogen atoms, eliminating in this way the necessity of using fossil hydrogen.^{14–17} To date, the electrochemical NRR to ammonia is the most promising alternative for real-life applications because of its relatively high efficiency and flexibility.^{18,19}

A large number of catalysts for the NRR process have been reported.^{20–27} However, almost all of them show low catalytic activity, reflected in low NH_3 yield and low faradaic efficiency (FE) values. There are several approaches to increase the efficiency of nitrogen reduction electrochemically, such as defect

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engineering,^{28,29} heteroatom doping,^{30–32} concurrent hydrogen evolution reaction suppression, *etc.*^{20–35} However, the effectiveness of current materials and approaches is still far from optimal, and they cannot be applied for ammonia production from nitrogen on an industrial scale.^{36,37}

Utilization of cheap and renewable (sun)light is another approach to increase the efficiency of nitrogen-to-ammonia conversion.^{38–42} A few materials and structures have recently been used for the photoelectrochemical NRR.^{43–45} Because of the redox activity of photo-excited charge carriers, most of these materials utilize the UV part of the sunlight spectrum but the utilization of near-infrared (NIR) wavelength from the solar spectrum is of greatest interest for photo-electrochemical processes, including the NRR.^{46–52} Plasmon-based photosensitization is one of the promising ways to utilization of almost all wavelengths from the sunlight spectrum in the NRR.^{53–56}

So, actually intensive current research is being focused on NRR efficiency enhancement by utilization of plasmon triggering.^{57–62} In turn, the plasmon effect on the photoelectrocatalytic reaction efficiency can be greatly enhanced by careful design of plasmon-active nanostructures (in particular – by creation of coupled plasmon nanostructures), which allows a gigantic value of local, plasmon-related, electric field (EF) to be achieved.^{63–68} Nevertheless, until now, plasmon coupling has mostly been applied in photoelectrochemical water splitting or CO₂ reduction^{69,70} but not in the NRR.

Recently, our research group demonstrated that LSP–SPP coupling under sunlight illumination significantly increases the nitrogen to ammonia conversion rate and faradaic efficiency.⁷¹ In this work, we describe an alternative design of NRR photoelectrodes, with enhanced redox-active coupled 2D materials and effective plasmon coupling, based on the experimental and theoretical choice of suitable plasmon active nanoparticles.

Experimental

A detailed description of used materials, sample preparation and characterization is given in the ESI.† Briefly, gC₃N₄ flakes were synthesized by urea annealing in air with subsequent delamination and purification. MoS₂ was prepared by hydrothermal approaches from corresponding precursors (sodium molybdate dihydrate and thiourea) in the presence of gC₃N₄ flakes. To obtain 2D nanosheets of gC₃N₄@MoS₂, the resulting powder was subjected to liquid nitrogen exfoliation followed by ultrasound treatment. The gold grating, responsible for the excitation of surface plasmon polaritons (SPPs), was prepared by sputtering of a 25 nm thick Au layer on a periodic polymer template.^{54,71} In the next step, the 2D/2D gC₃N₄@MoS₂ heterostructure was deposited on the Au grating surface using electrophoresis. In the final step, different plasmon active nanoparticles (spherical Au NPs, spherical Ag NPs, cubic Au NPs, urchin-like Au NPs, and triangle Ag NPs) were prepared *via* a wet chemical route and further deposition of gC₃N₄@MoS₂ onto the Au grating surface.

The electrochemical or photo-electrochemical catalytic activities of the samples were studied at room temperature under illumination with a sunlight simulator or in the dark,

both using a PalmSens 4 potentiostat (Palm Instruments, Netherlands) in a three-electrode mode and an H-type cell separated by a Nafion membrane. Photoelectrocatalytic N₂ reduction experiments were carried out in chronoamperometric mode in 0.1 M Na₂SO₄ mixture solution which contained 20 wt% ([C₄mpyr][eFAP]) and which was purged with high-purity N₂ gases (purging with Ar or Air was used in control experiments) for 30 min before the experiment and then continuously purged with nitrogen during experiments. The amount of ammonia produced was determined photometrically and calculated using a calibration curve prepared by measuring the adsorption spectra of model solutions using the KIT test.

Results and discussion

Schematic representation of the proposed experimental concept

The scheme of sample preparation is shown in Fig. 1. In the first step, the 2D/2D gC₃N₄@MoS₂ heterostructure was prepared and deposited on the surface of the plasmon-active gold grating (responsible for the SPP excitation). Such structure was utilized for the NRR under “simple” plasmon triggering of gC₃N₄@MoS₂ redox activity. Alternatively, plasmon-active nanoparticles with different shapes and compositions were deposited on the sample surface (*i.e.*, on the surface of Au grating/gC₃N₄@MoS₂ flakes). Plasmon active nanoparticles ensure the excitation of localized surface plasmon resonance (LSP). The 2D nature of catalytically active gC₃N₄@MoS₂ provides appropriate gaps between the Au grating and metal nanoparticles. In the space between plasmon active nanostructures, where the redox active material, gC₃N₄@MoS₂ flakes, is located the plasmon coupling (*i.e.* in SPP–LSP coupling) and energy concentration arise. The utilization of different metal nanoparticles will ensure different efficiencies of plasmon coupling, and in turn different kinetics and efficiencies of the NRR, as was initially assumed.

Characterization of gC₃N₄@MoS₂ flakes

Characterization of gC₃N₄@MoS₂ is presented in Fig. 2. First, FTIR spectra (Fig. 2A) indicate the presence of peaks characteristic of the structure of graphitized carbonitride: 1100–1700 cm^{−1}, responsible for the –C–N– and –C=N– vibrations; 808 cm^{−1} characteristic of triazine rings; and 3100–3300 cm^{−1} responsible for the NH₂-group stretching vibration. The characteristic peaks of MoS₂ (Fig. S1A†) are not well visible due to overlapping with the gC₃N₄ peaks. However, the presence of MoS₂ in the gC₃N₄@MoS₂ heterostructure is well visible from Raman spectra (Fig. 2B) where the peaks characteristic of the MoS₂ E_{2g} and A_{1g} vibration modes (377 and 403 cm^{−1}) appear. Compared with the Raman spectrum of the pristine MoS₂ (Fig. S1B†), the peaks are shifted only slightly, which observation suggests the similar crystal structure of MoS₂ in the gC₃-N₄@MoS₂ and control powder. The survey XPS spectrum of gC₃N₄@MoS₂ (Fig. 2C) indicates the presence of both molybdenum and sulphur, as well as carbon and nitrogen from gC₃N₄. Calculated from the survey XPS spectra, the surface elemental composition of gC₃N₄@MoS₂ (as well as control gC₃N₄ and



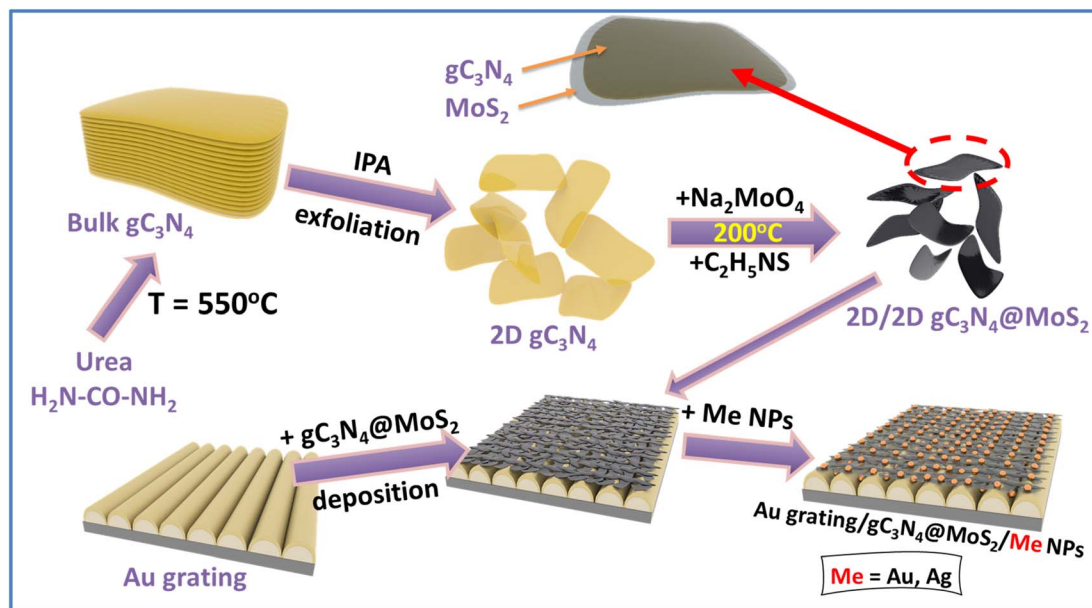


Fig. 1 Schematic representation of sample preparation.

MoS₂) is presented in Table 1. As is evident, the ratio of Mo and S in gC₃N₄@MoS₂ and MoS₂ is close to the stoichiometric one, confirming the correct composition of molybdenum disulfide produced on the gC₃N₄ nanoflake surface. Shifts of Mo 3d_{5/2} and 3d_{3/2} peaks (in comparison with the control MoS₂ powder) are evident from the high resolution XPS spectra (Fig. S2†). A similar shift can also be observed when comparing the S 2p_{3/2} and S 2p_{1/2} peaks of both samples. A positive shift in the position of the C 1s peaks from the gC₃N₄@MoS₂ sample in

Table 1 Elemental concentration calculated from XPS spectra

Sample	Elemental concentration (at%)			
	Mo	S	C	N
MoS ₂	31.89	68.11	—	—
gC ₃ N ₄	—	—	45.52	54.48
gC ₃ N ₄ @MoS ₂	20.35	39.31	19.87	20.47

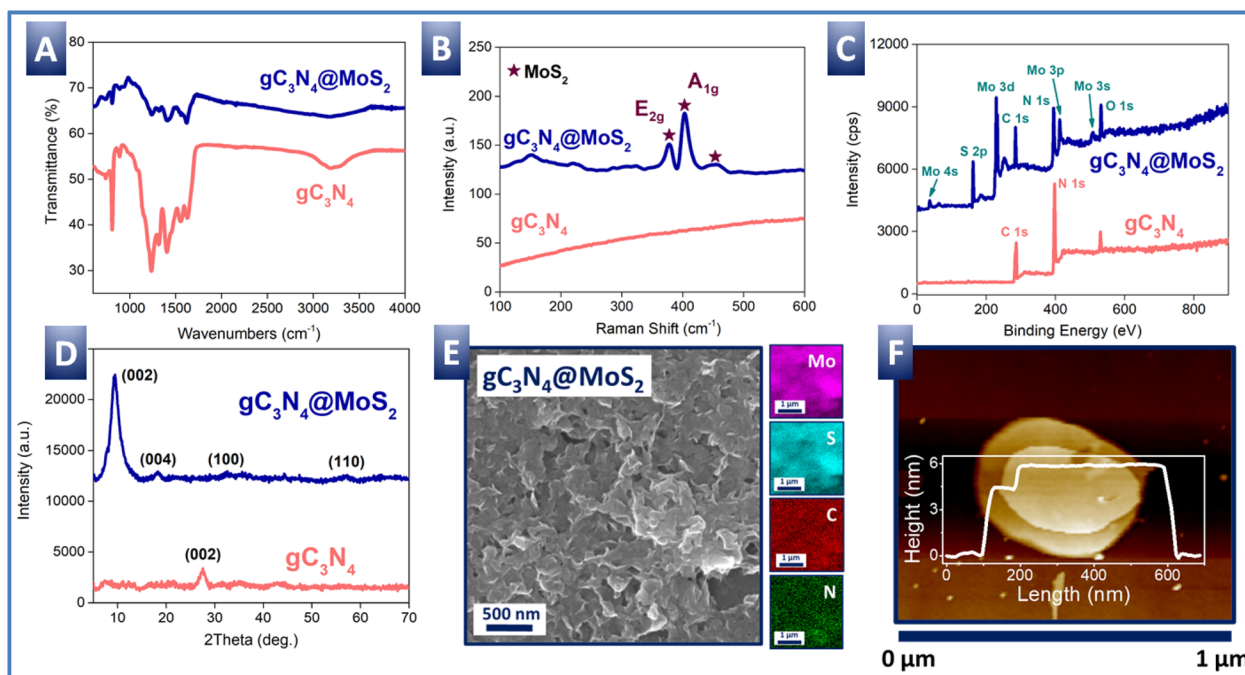


Fig. 2 gC₃N₄@MoS₂ characterization: (A)–(C) FT-IR, Raman, and XPS spectra; (D) XRD patterns; (E) SEM-EDX image with elemental mapping and (F) AFM images of gC₃N₄@MoS₂ flakes and the single flake profile.

comparison with control gC_3N_4 powder is also evident.^{72,73} The shifts indicate appropriate semiconductor coupling and related electron transfer from gC_3N_4 to MoS_2 .^{72,73} Moreover, a slight difference in the E_{2g} and A_{1g} peak positions in the Raman spectra of $\text{gC}_3\text{N}_4@\text{MoS}_2$ and pure MoS_2 (Fig. 2B and S1B†) also indicates the presence of interfacial electronic interactions (charge transfer) between the gC_3N_4 and MoS_2 phases.⁷⁴

Finally, the XRD pattern (Fig. 2D) confirms the good crystallinity of the $\text{gC}_3\text{N}_4@\text{MoS}_2$ sample. Peaks at 9.3° , 18.2° , 32.7° , and 56.9° well correspond to the 1T- MoS_2 phase. The main diffraction peak of MoS_2 at 9.3° ((002) plane) in the $\text{gC}_3\text{N}_4@\text{MoS}_2$ structure is slightly broader than that from the control MoS_2 sample (Fig. S1D† vs. 2D), which broadening indicates a slight decrease of MoS_2 crystallinity, when it was prepared in the presence of amorphous gC_3N_4 .

The morphology and 2D structure of the $\text{gC}_3\text{N}_4@\text{MoS}_2$ structure were checked using SEM-EDX, AFM and HRTEM-EDX methods (Fig. 2E, F and S3†).

The AFM measurements confirm the two-dimensional nature of the $\text{gC}_3\text{N}_4@\text{MoS}_2$ structure, with two well-coupled flakes with different thicknesses (characteristic structure morphology is presented in Fig. 2F, while Fig. S4† shows the measurements of the samples prepared separately – the measurements were performed at different places). The thickness of the final coupled structure is about 5–6 nm, which is larger compared to that of the control MoS_2 nanoflakes (Fig. S1E†). HRTEM images also confirm the two-dimensional

orientation of the samples, whereas the results of Mo, S, C and N EDX mapping show a uniform distribution of these elements in the flake structure (Fig. S3†). Similar results were obtained with the SEM-EDX technique, which indicates that C and N elements (*i.e.* gC_3N_4) are uniformly distributed in the same way as Mo and S, which finding may suggest that the gC_3N_4 structure was indeed a substrate for the growth of the MoS_2 structure in the hydrothermal synthesis (Fig. S5†). So, it can be concluded that the MoS_2 structure is uniformly grown on the gC_3N_4 nanoflake surface.

Characterization of the $\text{Au/gC}_3\text{N}_4@\text{MoS}_2$ structure

In the next step, the deposition of $\text{gC}_3\text{N}_4@\text{MoS}_2$ on a plasmon-active Au grating (Fig. S6†) was performed in order to utilize plasmon assistance for the nitrogen reduction reaction (NRR) enhancement. The deposition of $\text{gC}_3\text{N}_4@\text{MoS}_2$ flakes on the Au grating surface was performed in the electrophoretic regime and resulted in a uniform flake distribution over the entire plasmon-active Au grating area. Evident changes of sample surface morphology after the flake deposition were observed with utilization of AFM and SEM measurements (Fig. 3 and S6†). The grating surface becomes significantly rougher, but its apparent periodicity is conserved, both indicating that the flakes cover grating tops and also penetrate the valleys. Micro-EDX and macro-Raman maps show that the signal from $\text{gC}_3\text{N}_4@\text{MoS}_2$ is uniformly spread over the sample areas. UV-Vis spectra of created samples are shown in Fig. 3D. The pristine

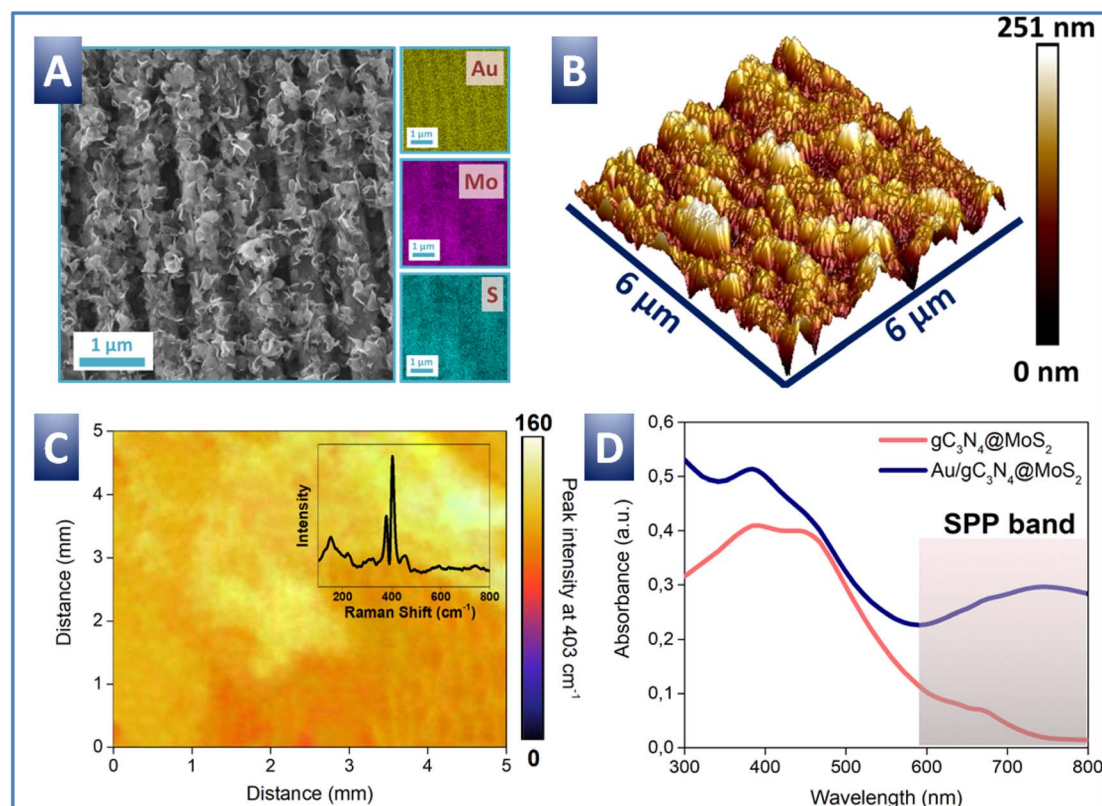


Fig. 3 (A) and (B) SEM-EDX and AFM images of the surface morphology of $\text{Au/gC}_3\text{N}_4@\text{MoS}_2$; (C) Raman mapping of $\text{gC}_3\text{N}_4@\text{MoS}_2$ distribution on the Au grating surface; (D) UV-Vis spectra of $\text{gC}_3\text{N}_4@\text{MoS}_2$ flakes and the $\text{Au/gC}_3\text{N}_4@\text{MoS}_2$ structure.



$\text{gC}_3\text{N}_4@\text{MoS}_2$ flakes (measured in suspension) show a wide absorption band, located at shorter wavelengths, and attributed to electron excitation from the valence to the conduction band (photoexcited electrons can subsequently participate in the NRR). Measurements of flakes, deposited on the Au grating surface, reveal the presence of an additional plasmon-related absorption peak, located at longer wavelengths. The SPP absorption band is well evident even in the spectrum of the pristine Au grating and is slightly shifted after the deposition of $\text{gC}_3\text{N}_4@\text{MoS}_2$ (Fig. S7†). The plasmon triggering can efficiently contribute to charge carrier excitation as well as their effective separation and energy enrichment. In such a way, the catalytic activity of the flakes is enhanced, and longer light wavelengths can be also involved in the NRR. Thus, we can conclude that the $\text{Au/gC}_3\text{N}_4@\text{MoS}_2$ structure is able to utilize almost the full sunlight spectrum and potentially utilize the absorbed energy for the production of ammonia from nitrogen.

NRR with utilization of the $\text{Au/gC}_3\text{N}_4@\text{MoS}_2$ structure

First, in order to confirm the absence of plasmon-active substrate catalytic activity (*i.e.* nitrogen reduction on the gold grating surface without addition of $\text{gC}_3\text{N}_4@\text{MoS}_2$), control LSV measurements were performed (Fig. S6C†). In this case, the LSV curve inflections and shapes measured in the presence of both argon and nitrogen were almost the same, indicating that the plasmon active gold grating is catalytically inactive. So, all subsequently obtained results should be attributed to the redox activity of deposited $\text{gC}_3\text{N}_4@\text{MoS}_2$ flakes.

In the next step we proceed to the utilization of Au grating/ $\text{gC}_3\text{N}_4@\text{MoS}_2$ samples for the NRR, performed in photo-electrochemical mode (Fig. 4) involving illumination with wide-

spectrum simulated sunlight. First, the LSV curves were measured with electrolyte purging with argon and nitrogen (Fig. 4A). In the case of argon purged electrolyte, we observed the HER related on-set potential at -0.45 V. Utilization of sunlight illumination (also under argon purging) results in a slight shift of LSV curves, revealing the fact that the plasmon triggering activates $\text{gC}_3\text{N}_4@\text{MoS}_2$ redox activity. A significant change in LSV curve shape was observed when the electrolyte solution was saturated with nitrogen and the HER was partially blocked by the addition of ionic liquid. The onset potential was shifted from -0.29 V to -0.45 V *vs.* RHE, indicating the occurrence of some concurrent process to the HER process (with a high probability for the NRR). Even more pronounced shift of the LSV curve was observed with utilization of sunlight illumination and nitrogen purging. In this case the onset potential was shifted from -0.45 to -0.28 V *vs.* RHE, while the overpotential at 3 mA cm^{-2} was decreased by *ca.* 0.07 V. So, we can assume that the triggering with wide spectrum light increases the efficiency of the NRR. This phenomenon can be attributed to both, excitation of inner electrons in $\text{gC}_3\text{N}_4@\text{MoS}_2$ (with utilization of shorter wavelengths) and plasmon triggering (involving longer wavelengths).

A series of NRR tests were subsequently performed in the photo-electrochemical regime under different constant potentials (Fig. 4B). Experiments were followed by quantitative measurements of the amount of produced ammonia, performed by the photometric method (also taking into account the potential pH changes). As is evident, the $\text{Au/gC}_3\text{N}_4@\text{MoS}_2$ sample produces $640.3 \mu\text{g h}^{-1} \text{ mg}_{\text{cat}}^{-1} \mu\text{mol}$ of ammonia (Fig. 4C) with utilization of -0.4 V external potential under simulated sunlight irradiation, which is 11.6 times higher than that measured in the dark (Fig. 4D). The NRR proceeds on the

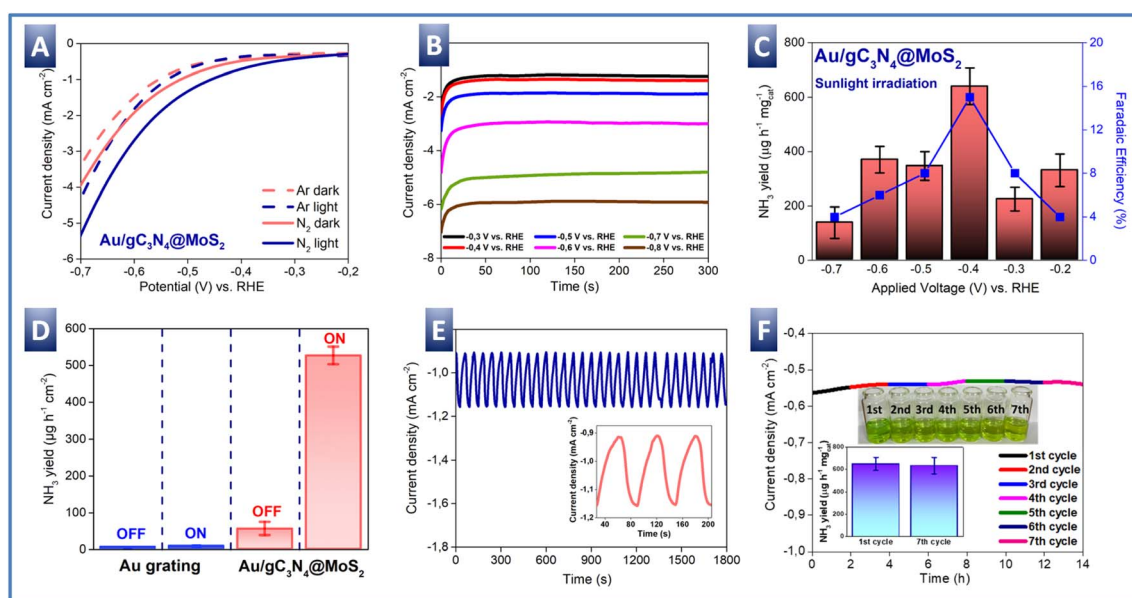


Fig. 4 (A) LSV curves of $\text{Au/gC}_3\text{N}_4@\text{MoS}_2$ utilized as the working electrode under N_2 and Ar bubbling in the dark or under illumination with simulated sunlight; (B) current densities measured in the chronoamperometry regime at different potentials; (C) NH_3 yield and faradaic efficiency, obtained on the $\text{Au/gC}_3\text{N}_4@\text{MoS}_2$ photoelectrode surface under different potentials; (D) yields of NH_3 obtained on the surface of the pristine Au grating and the $\text{Au/gC}_3\text{N}_4@\text{MoS}_2$ system with (ON) or without (OFF) sample illumination; (E) NRR performed in the light switch ON–OFF regime, and (F) long-term stability test of NRR activity of the $\text{Au/gC}_3\text{N}_4@\text{MoS}_2$ photoelectrode.



$\text{gC}_3\text{N}_4@\text{MoS}_2$ surface (the pristine Au grating shows almost no NRR activity – see Fig. 4D, in agreement with Fig. S6C†). So, it can be concluded that the light triggering (including both, direct or plasmon-assisted triggering of $\text{gC}_3\text{N}_4@\text{MoS}_2$ flakes) results in perfect NRR efficiency. Finally, calculated faradaic efficiency reaches the very good 15.1% value under the optimal experimental conditions (*i.e.* under sample illumination and application of -0.4 V external potential).

The impact of switching light on/off is additionally demonstrated in Fig. 4E, where an immediate increase of current density after switching light on and its decrease after the switching light off are demonstrated. Switching light on is also accompanied by an apparent decrease of charge transport resistance between the photoelectrode and nitrogen saturated electrolyte (Fig. S8†). The overall kinetics and speed of structure response to light illumination (in a “seconds” range) can suggest that plasmon assistance proceeds through the acceleration of the electronic process rather than through plasmon-assisted, material heating. Fig. 4F shows sample stability over 14 hours of continuous utilization in the photoelectrochemical regime. Only little changes in the current density as well as in the amount of ammonia produced ($640.3 \mu\text{g h}^{-1} \text{mg}_{\text{cat}}^{-1}$ before and $633.5 \mu\text{g h}^{-1} \text{mg}_{\text{cat}}^{-1}$ after photo-electrode utilization) during the stability test period (Fig. S9B†) were observed. Additional measurements of the surface morphology and electrochemical activity (SEM-EDX and LSV) confirm the absence of the apparent changes of both parameters (Fig. S10†).

Control NRR experiments – impact of particular materials and plasmon assistance

We also performed a range of control experiments with the aim to estimate the particular contribution of used materials and highlight the role of plasmon triggering. First, utilization of Au/ MoS_2 and Au/ gC_3N_4 photoelectrodes instead of the Au/ $\text{gC}_3\text{N}_4@\text{MoS}_2$ photoelectrode results in a significantly lower NRR efficiency due to the absence of redox-active centres (Au/ gC_3N_4) or inefficient absorption of short light wavelengths (Fig. S11–S13†). A similar decrease in NRR efficiency, observed in the absence of a neighbouring Au grating (Fig. S12†), confirms the significant impact of plasmon triggering. A control hydrazine test during photoelectrochemical experiments with utilization of the Au/ $\text{gC}_3\text{N}_4@\text{MoS}_2$ photo-electrode proves the absence of production of undesired compounds (Fig. S9†). In order to confirm the fact that ammonium cations are formed from nitrogen delivered to the solution from the air, NMR control experiments were performed with utilization of purging with $^{14}\text{N}_2$ or $^{15}\text{N}_2$ and $(^{14}\text{NH}_4)_2\text{SO}_4$ or $(^{15}\text{NH}_4)_2\text{SO}_4$ solutions as a control (Fig. S14†). From subsequently measured NMR spectra it is clear that created NH_3 really utilizes the delivered gas as a nitrogen source.^{75–77}

NRR with utilization of the plasmon-coupled Au/ $\text{gC}_3\text{N}_4@\text{MoS}_2@\text{MeNPs}$ system – calculation results and structure optimization

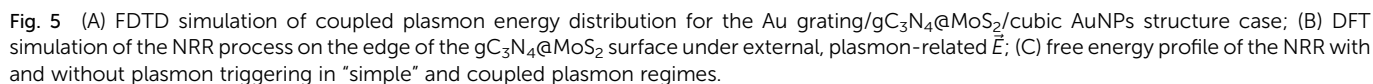
In the next step, we proceed to plasmon triggering of $\text{gC}_3\text{N}_4@\text{MoS}_2$ NRR activity with utilization of coupled plasmon-active

nanostructures. Unlike the previous case, such a system provides a higher enhancement of local plasmon strength in the space between the Au grating and plasmon-active nanoparticle(s), *i.e.*, in the place where $\text{gC}_3\text{N}_4@\text{MoS}_2$ flakes are located. For realization of the coupled plasmonic system, additional deposition of metal nanoparticles on the top of the Au/ $\text{gC}_3\text{N}_4@\text{MoS}_2$ photo-electrode was used.

Before experiments, finite difference time domain (FDTD) and density functional (DFT) calculations were performed to estimate the impact of coupled plasmon triggering on the NRR efficiency and to optimize structure design.⁷¹ The calculated distribution and local values of plasmon-related electric fields are presented in Fig. S15† as a function of different shapes and compositions of top-deposited nanoparticles (*i.e.* with a $\text{gC}_3\text{N}_4@\text{MoS}_2$ spacer between the Au grating and nanoparticles). The shapes of nanoparticles (spherical, triangle, cubic, and urchin-like) and their optical properties are summarized in Fig. S16.† As can be seen from the FDTD simulation, the local energy values in the presence of metal nanoparticles (coupled with the Au grating through the $\text{gC}_3\text{N}_4@\text{MoS}_2$ spacer) are several orders of magnitude higher than in the case of a simple grating. The best concentration of electric field energy in the $\text{gC}_3\text{N}_4@\text{MoS}_2$ location is found for cubic Au nanoparticles (Fig. S15†). This case is presented also in Fig. 5A, where a significant concentration of plasmon energy even inside $\text{gC}_3\text{N}_4@\text{MoS}_2$ flakes or in their nearby space is evident (unlike, for example, in the case of gold nanourchins). Thus, the most efficient plasmon triggering of $\text{gC}_3\text{N}_4@\text{MoS}_2$ catalytic activity could be expected with cubic gold nanoparticles. As is evident from the FDTD simulation, utilization of different nanoparticles results in a different value of the local electric field. In our DFT model, we used only the value of the electric field strength as a uniform field corresponding to a given type of nanoparticles or their absence.

Fig. 5B shows the particular NRR steps occurring on the $\text{gC}_3\text{N}_4@\text{MoS}_2$ surface (calculated using the DFT approach) with plasmon triggering (designated as a plasmon related electric field – \vec{E} , achieved on a simple grating or a grating coupled with Au nanocubes). According to a previous study,⁷² the Mo edge sites of the $\text{MoS}_2/\text{gC}_3\text{N}_4$ heterostructure are energetically more favourable as the active sites for the reaction. During the relaxation of the geometry of the bilayer surface, the gC_3N_4 plane was curved in such a way that boundary effects arose near the binding site of the N_2 molecule on the edge of MoS_2 , mainly manifested in the additional orientation of bound protons with subsequent correction of the binding energy. Although previous DFT studies of similar bilayer systems have considered the flat structure of gC_3N_4 ,⁷² several other DFT studies of individual gC_3N_4 layers have produced curved surfaces consistent with that obtained in our calculations.^{78–80} As shown in Fig. 5C (red line), in the free energy profile of sequential steps of the NRR in the absence of an external electric field, there are two main hydrogenation transitions corresponding to the potential determining steps (PDS) of the reaction. The first barrier with a height of 1.25 eV is associated with the formation of the $^*\text{N}-\text{NH}$ complex, and the second barrier with a height of 1.45 eV is related to the detachment of the first NH_3 molecule and the





NRR with utilization of the plasmon-coupled Au/gC₃N₄@MoS₂@MeNPs system – experimental results

In the case of the coupled plasmonic regime (*i.e.* combination of the Au grating and Au cubic nanoparticles) we obtained an electric field near the reaction site in the 12–75 kV m⁻¹ range for various types of considered nanoparticles (Fig. S15† and 5A). Fig. 5C (brown line) shows the free energy profile of the NRR under conditions of an applied field of 75 kV m⁻¹ (corresponding to utilization of cubic Au nanoparticles), at which an additional decrease in the first barrier by 0.25 eV and the second barrier by 0.2 eV is observed. The applied external, plasmon-related, electric field generally stabilizes the doublet states in the *N-NH, *N positions and destabilizes the singlet state in the *N-NH₂ position. This ratio in the influence of the electric field on the energy of singlet and doublet configurations of intermediates for a field of the order of 75 kV m⁻¹ leads to an almost barrier-free NRR after the first PDS step, which may correspond to the significant increase in the chemical yield of NH₃ observed in the experiment.

The detailed characterization of the best sample structure (Au grating/gC₃N₄@MoS₂/cubic Au NPs, further designated as Au/gC₃N₄@MoS₂/AuNPs) is presented in Fig. 6. Fig. 6A and B

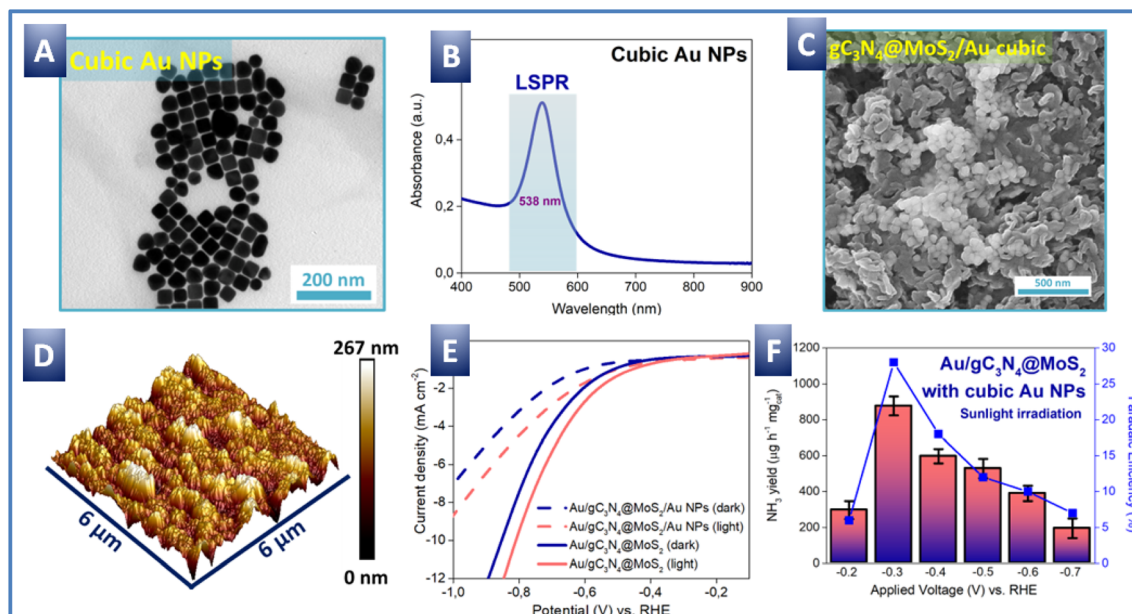


Fig. 6 (A) TEM image and (B) UV-Vis spectrum of cubic Au NPs; (C) SEM and (D) AFM images of Au/gC₃N₄@MoS₂ coupled with top-deposited cubic AuNPs; (E) LSV curves measured on the Au/gC₃N₄@MoS₂ and Au/gC₃N₄@MoS₂/AuNPs surface with and without light illumination; (F) NH₃ yield and faradaic efficiency obtained on the Au/gC₃N₄@MoS₂/AuNPs surface in the photoelectrochemical regime.

show the shape and optical properties of cubic AuNPs. TEM images show the homogeneous distribution and cubic shape of nanoparticles, with a size comparable with the “grating-like” surface pattern (*i.e.* nanoparticles are able to penetrate the grating valleys). The cubic AuNPs also efficiently absorb the light in the 500–600 wavelength range, due to plasmon excitation. This spectral location of the plasmon band can partially compensate the lower absorption windows of the Au/gC₃N₄@MoS₂ structure (Fig. 3A). The surface morphology of Au/gC₃N₄@MoS₂ after the deposition of cubic AuNPs is presented in Fig. 6C and D. The SEM image indicates the presence of 30–40 nm cubic gold nanoparticles on the sample surface (comparison of the gC₃N₄@MoS₂ surface before and after Au nanocube deposition is given in Fig. S19†). The changes of surface morphology are also evident from the AFM scan. Compared to the pristine Au grating or Au grating with

deposited flakes, the deposition of cubic gold nanoparticles leads to slight flake re-orientation.

To verify the impact of coupled SPP–LSP triggering, the LSV curves were collected first (measurement of both Au/gC₃N₄@MoS₂/AuNPs and Au/gC₃N₄@MoS₂ samples is presented in Fig. 6E). It can be seen that in the dark the Au/gC₃N₄@MoS₂/AuNPs surface is slightly less catalytically active compared to Au/gC₃N₄@MoS₂, which effect can be explained by partial blocking of the gC₃N₄@MoS₂ surface by top-deposited nanoparticles. However, light triggering also has an apparent impact on the LSV curve shape in the case of plasmon coupling (*i.e.* in the Au/gC₃N₄@MoS₂/AuNPs case). Both onset and offset potentials were shifted towards lower (absolute) values. In turn, the amount of released ammonia and calculated faradaic efficiency are presented in Fig. 6F as a function of potential, used in photoelectrochemical experiments. As is evident, excellent NH₃

Table 2 Comparison of the present results with those previously published

Catalyst	Electrolyte	Potential (V vs. RHE)	NH ₃ yield (μg h ^{−1} mg _{cat} ^{−1})	FE (%)	Ref.
Zn ¹ N–C	0.1 M KOH	−0.3	16.1	11.8	81
Ru SAs/Ti ₃ C ₂ O	0.1 M HCl	−0.2	27.56	23.3	82
MXene/TiFeO _x	0.05 M H ₂ SO ₄	−0.2	21.9	25.4	83
MoSAs–Mo ₂ C/NCNTs	5 mM H ₂ SO ₄	−0.25	16.1	7.1	84
Ru/SnO _{2–x}	0.2 M K ₂ SO ₄	−0.2	32.4	16.2	85
FeMo ₃ S ₄	0.5 M LiClO ₄	−0.3	65.3	19.2	86
PdH _{0.43} NRs	0.1 M Na ₂ SO ₄	−0.2	17.53	18.6	87
CoPc–RGO 1D–2D	0.1 M K ₂ SO ₄	−0.2	143.38	43.7	88
Fe ₃ C/Fe ₃ O ₄ @C-950	0.1 M HCl	−0.2	25.7	22.5	89
Au grating/gC ₃ N ₄ @MoS ₂	0.1 M Na ₂ SO ₄	−0.4	642.1	15.1	This work
Au grating/gC ₃ N ₄ @MoS ₂ /Au NPs	0.1 M Na ₂ SO ₄	−0.3	882.1	28.1	This work



yield ($882.1 \mu\text{g h}^{-1} \text{mg}_{\text{cat}}^{-1}$) and faradaic efficiency (28.1%) were reached at the optimal potential, equal to -0.3 V (unlike the $\text{Au/gC}_3\text{N}_4\text{@MoS}_2$ case, where the optimal faradaic efficiency was reached at -0.4 V , which was 15.1%). So, utilization of plasmon coupling leads to a decrease in optimal potential, required for the NRR and simultaneously to an increase in faradaic efficiency, as well as in the overall ammonia production yield.

Finally, it should be noted that the results obtained in the coupled plasmonic regime overperform most of the previously published ones^{81–89} in terms of both faradaic efficiency and ammonia yield (Table 2). Experimental results perfectly correlate with previous simulation of the Au grating – Au nanocube combination, where the plasmon related energy penetrates the $\text{gC}_3\text{N}_4\text{@MoS}_2$ space. The resulting high local electric field allows the redox activity of coupled $\text{gC}_3\text{N}_4\text{@MoS}_2$ to be significantly increased and decreased according to the energy demand of the NRR (despite some blocking of the $\text{gC}_3\text{N}_4\text{@MoS}_2$ surface by redox-inactive Au nanoparticles).

Conclusion

In this work, the rational design of a hero-photoelectrode for efficient NRR with light energy assistance is proposed. As a catalytic material, highly redox active, coupled $\text{gC}_3\text{N}_4\text{@MoS}_2$ 2D flakes are used. Flakes were combined with plasmon-active nanostructures for efficient absorption and utilization of sunlight energy. Plasmon triggering was performed in two modes, with utilization of SPP-based triggering through the immobilization of the flakes on the surface of the plasmon-active Au grating or in the coupled plasmon regime, through the sandwiching of redox-active flakes between the Au grating and plasmon active nanoparticles (Au and Ag nanoparticles with different shapes were used). The FDTD simulation was used to estimate the local value of coupled plasmon strength and the local value of the plasmon-related electric field. The best penetration of coupled plasmon energy was predicted for the combination of the Au grating with cubic Au nanoparticles and the $\text{gC}_3\text{N}_4\text{@MoS}_2$ spacer between. In addition, the NRR process under plasmon triggering was simulated using a range of DFT calculations, also taking into account the FDTD results. Theoretical calculation indicates the ability to decrease the NRR energy demand (in particular – activation barrier of rate determining steps) under plasmon triggering, especially pronounced in the coupled plasmon regime. Theoretical results were subsequently verified in several experiments. In particular, with utilization of simple plasmon triggering (using solely the Au grating) we achieve $642.1 \mu\text{g h}^{-1} \text{mg}_{\text{cat}}^{-1} \text{NH}_3$ production yield and 15.1% faradaic efficiency. The employment of plasmon coupling allows the decrease of the optimal NRR potential and simultaneous increase of the NH_3 production yield up to $882.1 \mu\text{g h}^{-1} \text{mg}_{\text{cat}}^{-1}$ and faradaic efficiency up to 28.1%.

Data availability

The data presented in this study are available <https://zenodo.org/records/12722224>.

Conflicts of interest

There are no conflicts to declare.

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